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Electrical Characterization of SnO₂ based thick film resistors loaded with an optimized Sb: Sn alloy

B. R. Sharma¹, S U Shinde², N. D. Chaudhari³

^{1,2,3}Dept. of Physics Pratishthan Mahavidyalaya Paithan, Dist Aurangabad, M.S.

Abstract: Thick Film Resistors (TFRs) are extensively being used in hybrid electronic technology, wherein high standards of electrical parameters and stability in changing thermal environment are required especially in space-research based industries. In the present paper, the optimized alloy Sb_{0.6}:Sn_{0.4} of 5-10 μ m size was loaded in SnO₂ nano-sized powder synthesized by sol-gel method, to produce range of resistive pastes. Thick Film Resistors fabrication and their electrical and material characterization using XRD and SEM studies have been reported. The fall in sheet resistivity ρ_s against loading fraction of optimized alloy Sb_{0.6}:Sn_{0.4} in SnO₂ nano-sized particles has been examined using percolation/effective medium theory.

Keywords: Thick film resistor, Sheet Resistivity, TCR, Firing Temperature.

I. INTRODUCTION

The hybrid microelectronic thick film technology has been extensively used wherein the screen printed films are fired at high temperature can be used as planar passive components, such as, resistors, capacitors, conducting terminations etc. However thick film pastes/inks are based on expensive noble metals like Ru, RuO₂, Pd, gold, etc. The Thick Film Resistors (TFRs) are superior in performance, such as stability against load, low thermal noise, high current carrying capacity, non-inductive in nature, could be used at high frequencies¹⁻³. The cost effective SnO₂ nanoparticles can be easily synthesized by sol-gel method, may be used as a functional material in the composition of TFR pastes⁴⁻⁶. S.H. Bhide et al used antimony as a dopant (5% by weight) in SnO₂ and reported sheet resistivity of 1M Ω/\square and temperature coefficient of resistance (TCR) about -2000 PPM/°C⁷. M. R. Kadam et al reported that the film resistive pastes using SnO₂ as a functional material and loaded by SnCl₂ gives the minimum sheet resistance as $\rho_s = 5 \text{ K}\Omega/\square$ and TCR (α) as low as -950 ppm/°C and the paste containing SnO₂ : (Sb 5%) loaded by SnCl₂ resulted in the range of various resistive pastes⁸. Further Kattimani et al reported when Sb:Sn alloy loaded in SnO₂ results in sudden fall in sheet resistivity at 5 % of Sb:Sn doping from 10¹² Ω/\square to 750 Ω/\square followed by continuous steady decrease of resistivity and TCR at 90 % Sb:Sn alloy loading at 170 Ω/\square and TCR about -950 ppm/°C⁹. The research in nanoparticle physics is of interest due to high sensitivity for hydrogen, humidity, and LPG gas sensors^{4-6,10}. It is interesting to study electrical properties in the variation of optimized Sb_{0.6}:Sn_{0.4} alloy of 5 μ m size loaded in SnO₂ nano-sized particles as cost effective thick film resistors. The fall in resistivity over the whole range of weight fraction W_m in SnO₂ based thick films is predicted/expected to be similar to B. E. Springette's percolation model based on conducting particles mixed in uniform dielectric matrix¹¹.

II. EXPERIMENTAL PROCEDURE

A. Synthesis of SnO₂ and Sb:Sn Alloy

The Stannous Oxide (SnO₂) nano-sized particles were synthesized using standard sol-gel technique. The SnCl₄.5H₂O (AR grade) was dissolved in distilled water to make a 0.1 M solution. The prepared solution of SnCl₄ and H₂O was mixed with ammonia (NH₄OH, AR grade). The resulting precipitation was washed thoroughly with distilled water for longer times to remove excess (Cl⁻ and NH₄⁺) Ions. The filtered resulting milky-white cake / gel were dried for 24 hrs at 100 °C under the IR lamp. The dried precipitate was ground into fine powder using agate mortar pestle and filtered through a 250 meshsize nylon cloth. The resulting powder was sintered/ calcined for 4hrs at various temperatures (500-1100 °C) to obtain SnO₂ fine particles of various sizes ranging from 28-50 nm⁴. Fine powders of antimony (Sb) and tin (Sn), both in particle size 5-10 μ m are weighed in different proportions (20:80,40:60,50:50,60:40,80:20) and are thoroughly mixed in acetone medium by using ball mill for 12 hrs. The quartz tubes are used and vacuum sealed by LPG and Oxygen torch in blue-white flame after filling the dried cake/alloy powder at 10⁻⁵ torr using rotary-diffusion pump. The sealed tubes are heated to 630 °C in a resistive furnace for 3 hrs. Then after slowly cooled alloy is

removed/collected by breaking quartz tubes and crushed in agate mortar pestle and ball milled for 12 hrs in acetone medium, dried under IR lamp then filtered through 250 mesh nylon cloth, ready to mix in SnO₂ to formulate the paste and TFRs.

B. Preparation of SnO₂ based Sb:Snalloy thick film Resistors

The Stannic oxide fine powder prepared by the above method was used as the basic functional material. The SnO₂ based on optimized Sb_{0.6}:Sn_{0.4} alloy paste was prepared with 10 % of standard lead borosilicate glass frit as a permanent or inorganic binder; ethyl cellulose (EC) and butyl carbitol acetate (BCA), were added suitably (solid to liquid ratio 70:30 by weight) so as temporary binder to get a thixotropic and rheological paste¹². The paste was then screen printed on pure alumina (Al₂O₃) substrate (1" × 1/2"), dried for 4 hrs then fired at 800°C using induction heating for 45 minutes. For good electrical contact Silver electrodes were printed and dried under IR lamp after firing the films. The film thickness, as measured by light section microscope (BK 70 × 50 Carl Zeiss, Jena) with an accuracy of ±0.5 μm, varies from 20 to 30 μm and it is normalized to 1 mil or 25 μm. The d.c. resistance of the pattern with different aspect ratios (N = L/W = 1, 1.5, 2) was measured by digital electrometer (Keithley EA-614). The time-temperature profile of the induction furnace was chosen so as to give good adhesion of uniform thick film formulation without any blisters or holes. The thickness of the thick films were monitored by light section microscope and ρ_s is normalized to 25 μm thickness used to measure sheet resistivity defined by

$$\rho_s = \frac{\rho_B}{t} = \frac{R}{N} = \frac{R \cdot W}{L} \tag{1}$$

in the units of Ω/□. Where, ρ_B, R, t and N are the values of bulk resistivity, resistance, thickness and the aspect ratio (N = L/W = length/width) for the thick film resistor test pattern respectively. Resistor test pattern is having length L and width W for different values of N.

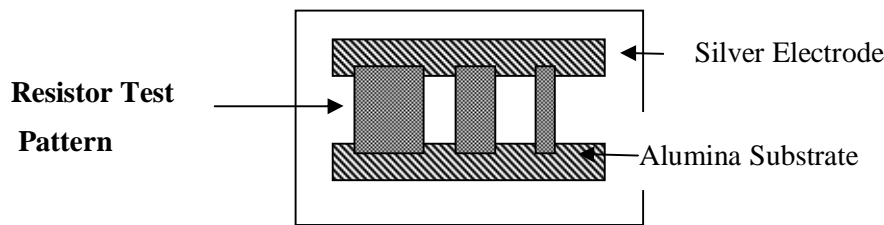


Fig. 1. Schematic representation of resistor test pattern on alumina substrate.

The temperature coefficient of resistance (TCR) is given by,

$$\alpha = \frac{1}{R(T)} \frac{dR(T)}{dT} = \frac{(R_1 - R_2)}{(R_2 \cdot T_1 - R_1 \cdot T_2)} \cdot 10^6 \text{ ppm/}^\circ\text{C} \tag{2}$$

Where, R₁ and R₂ are the values of resistors at the absolute temperatures T₁ and T₂ in linear region over R-T Characteristics in the range 30-130°C. The temperatures are monitored by temperature controller, based on alumel-chromel thermocouple using small resistive furnace.

C. X-ray analysis and Particle Size

The material characterization of TFRs was performed using X-ray diffraction and SEM techniques. Tin oxide occurs in various phases: orthorhombic, tetragonal, cubic or triclinic. But here only the tetragonal phase was revealed in x-ray analysis¹³. X-ray diffraction analysis of tin oxide powder calcined at various temperatures 500-1100 °C, as well as alloy powders made into thick films (suitable for resistors) was carried out using Philips PW-1840 diffractometer. Standard CuK_α radiation line having wavelength λ = 0.1542 nm was used as the X-ray source. The higher peak intensities of XRD pattern analysis reveals polycrystalline nature due to bigger grain size in the agglomerates of all the thick film resistors. Particle size analysis was made using the FWHM (β) width of the prominent diffraction peak and using the Debye-Scherrer formula,

$$D_{hkl} = 0.9\lambda / \beta \cos\theta \tag{3}$$

Where D_{hkl} is the diameter of the particles in the hkl direction, λ is the X-ray wavelength of source and β is the full angular width of the diffraction peak at half the maximum intensity for diffraction angle 2θ in radians. From the Fig. 2, it is observed that the particle size D in the range 28-52 nm increases linearly with the curing temperature T, indicating growth of crystallite grains.

III. THEORETICAL CONSIDERATIONS

B. E. Springette proposed effective medium theory that assumes insulator to be continuous medium in which spherical metal particles are randomly embedded. The simple cubic lattice model can be used for particulate system to explain the effective conductivity of the medium. As more and more metal particles are introduced, the lattice sites become more occupied in a random manner with each lattice site is associated a conductivity σ_i whose value depends upon whether the site is occupied by metal or insulator. In this way network of electrical conductance is developed. The probability P_i that a site is occupied by metal particle is V_m/f where V_m is the volume fraction of the metal and f is the packing fraction. For simple cubic, BCC and FCC f takes values 0.528, 0.68 and 0.74 respectively^{11,13-14}. Assume that all conductances are equal to $\bar{\sigma}$. Let one conductance be changed to back to its true value σ_i , examine the voltage difference between the V_i and the voltage across $\bar{\sigma}$ and voltage across $\bar{\sigma}$ far from σ_i is V . the conductance of the adjacent nodes of the network of conductances $\bar{\sigma} = (1/2)z \bar{\sigma}$ where z is the coordination number of the lattice. Consider such pair of nodes and consider the conductance across it, replacing the rest of the network by a conductance σ_n . If the current flowing in to the lattice is I , then all the conductances are equal to $\bar{\sigma}$, the voltage drop across the node is given by¹¹,

$$v = \frac{I}{(\sigma_n + \bar{\sigma})} = \bar{v}$$

There fore $\sigma_n = [\frac{1}{2}z - 1]\bar{\sigma}$ where $\bar{\sigma}$ is replaced by σ_i the voltage drop becomes,

$$v_i = \frac{I}{(\sigma_n + \sigma_i)} = \frac{v(\sigma_n + \bar{\sigma})}{(\sigma_n + \sigma_i)}$$

Substituting for $\sigma_n, v_i - \bar{v} = \bar{v}(\sigma_i - \bar{\sigma})/[\sigma_i + (\frac{1}{2}z - 1)\bar{\sigma}]$

By the definition of $\bar{\sigma}$, as all the conductances are replaced by their original values, $(v_i - \bar{v})$ should be averaged to zero. Thus if $P(\sigma)$ is the probability distribution of the conductance σ , we have for the cubic network,

$$\int \frac{P(\sigma)(\sigma - \bar{\sigma})}{(\sigma + 2\bar{\sigma})} d\sigma = 0 \tag{4}$$

where $P(\sigma)$ is a binary distribution, σ_m is the metallic conductivity, σ_α is the insulator conductivity, then the above equation becomes,

$$\frac{(\frac{v_m}{f})(\sigma_m - \bar{\sigma})}{(\sigma_m + 2\bar{\sigma})} + \frac{(1 - \frac{v_m}{f})(\sigma_\alpha - \bar{\sigma})}{(\sigma_\alpha + 2\bar{\sigma})} = 0 \tag{5}$$

This is a quadratic equation for $\bar{\sigma}$ where the root is given by,

$$4\bar{\sigma} = [\sigma'_\alpha + \sigma'_m] + [(\sigma'_\alpha + \sigma'_m)^2 + 8\sigma_\alpha\sigma_m]^{1/2}$$

or the average conductivity

$$\bar{\sigma} = [\sigma'_\alpha + \sigma'_m]/4 + \frac{[(\sigma'_\alpha + \sigma'_m)^2 + 8\sigma_\alpha\sigma_m]^{1/2}}{4} \tag{6}$$

Where,

$$\sigma'_\alpha = (2 - \frac{3v_m}{f})\sigma_\alpha \tag{7}$$

$$\sigma'_m = (\frac{3v_m}{f} - 1)\sigma_m \tag{8}$$

If σ_m and σ_α are known experimentally then $\sigma_m/\sigma_\alpha \approx 10^8$ we can plot a graph of $\log(\sigma_\alpha/\bar{\sigma})$ versus weight fraction or volume fraction of the metal in dielectric medium. For our experimental system SnO₂ nano-particles of average size nearly 50 nm are used as continuous dielectric matrix along with glass frits of 10 μm size (10% by weight) mixed with optimized Sb_{0.6}:Sn_{0.4} alloy particles of 5~10 μm size and varied as weight fraction w_m in the fired pastes at 800°C. For [SnO₂ nano-particles +10% glass frits] the average conductivity $\sigma_\alpha = 1.4 \cdot 10^{-10} \Omega^{-1} cm^{-1}$ and the conductivity of the pure Sb_{0.6}:Sn_{0.4} alloy $\sigma_m = 0.122 \Omega^{-1} cm^{-1}$ for [90% Sb_{0.6}:Sn_{0.4} + 10% glass frits] in the fired pastes.

IV. RESULTS AND DISCUSSIONS

As the XRD analysis show that SnO_2 and $\text{Sb}_{0.6}:\text{Sn}_{0.4}$ alloy decomposes in to free metal and metal oxides during the firing process. The experimental values for σ_α and σ_m $1.4 \times 10^{-10} \Omega^{-1} \text{cm}^{-1}$ and $0.122 \Omega^{-1} \text{cm}^{-1}$ are used for the calculation of Log of conductivity ratio ($\sigma_\alpha/\bar{\sigma}$) respectively, by using equations(6,7,8). The Springette's theoretical and experimental curves in percolation threshold differ on account of decomposition of SnO_2 and $\text{Sb}:\text{Sn}$ alloy in to free metals Sb , Sn and their oxides during firing process as revealed by XRD analysis, wherein their relative conductivities may not remain constant (Fig.3), as model considers it for constant conductivities of σ_α and σ_m for full range of weight fraction W_m in SnO_2 . Also the fired films are not homogeneous and uniform in microstructure and may develop pin holes and agglomerates as revealed by SEM micrographs Fig.6(a) to 6(d). The sheet resistivity and temperature coefficient of resistance (TCR) shows similar falling trend with loading percentage of $\text{Sb}_{0.6}:\text{Sn}_{0.4}$ alloy in SnO_2 nano-particles. Theoretical and experimental comparison of log of conductivity ratio and weight fraction is shown in Fig. 3, where it is observed that theoretical percolation threshold or sudden fall in conductivity ratio is observed with the weight fraction $w_m \sim 0.3$, however experimentally the percolation is observed at $w_m \sim 0.07$. This discrepancy in the values of model prediction of percolation and observed percolation may be explained on the basis of non-spherical nature of particles and porosity of the fired polycrystalline nature of thick films as seen in the SEM micrographs. The chemical reactions occur during firing process may alter electrical conductivity of the alloy and free metal particles as revealed by XRD analysis.

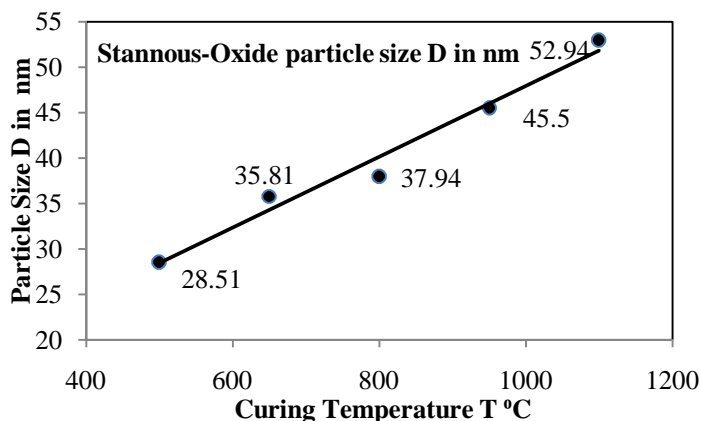


Fig.2. Variation of particle size of SnO_2 with Curing Temperature

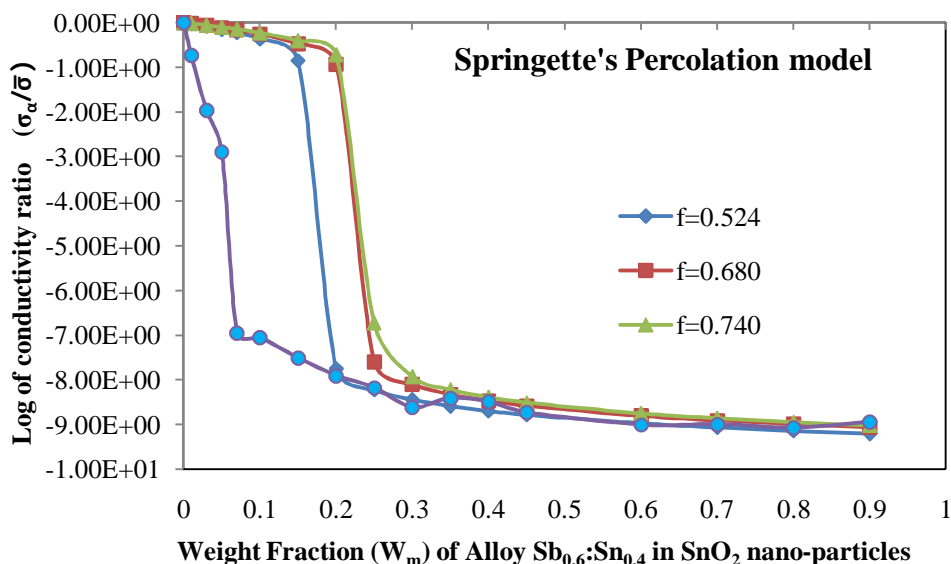


Fig. 3. The variation of electrical conductivity ratio $\text{Log}(\sigma_\alpha/\bar{\sigma})$ versus W_t .

fraction of $Sb_{0.6}:Sn_{0.4}$ alloy in SnO_2 nano-particles along with Springette's percolation model.

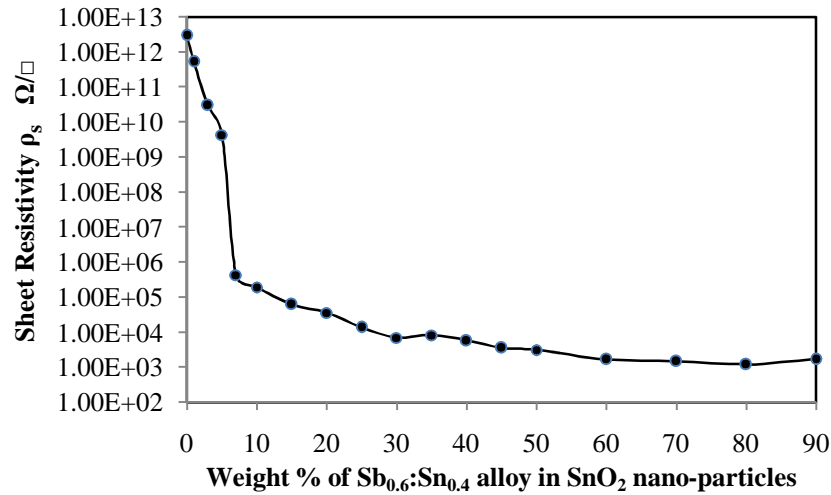


Fig. 4. The variation of electrical sheet resistivity (ρ_s) versus weight % of $Sb_{0.6}:Sn_{0.4}$ alloy in SnO_2 nano-particles.

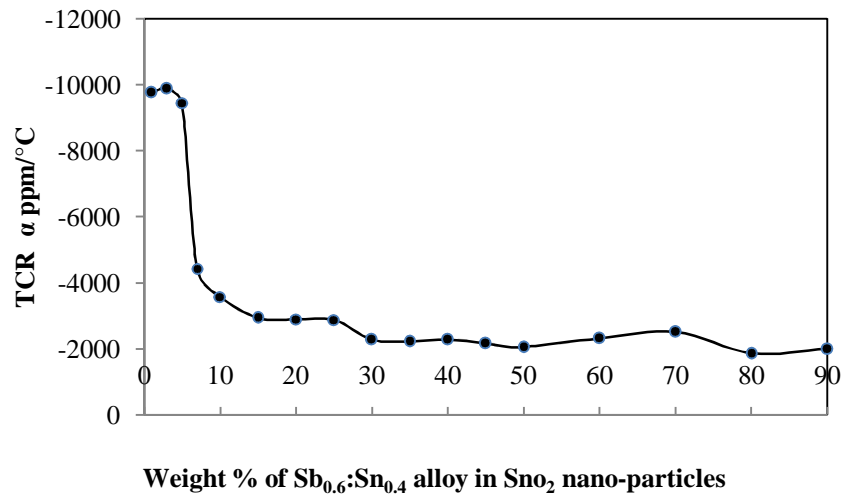


Fig. 5. The variation of Temperature coefficient of resistance (α) versus weight % of $Sb_{0.6}:Sn_{0.4}$ alloy in SnO_2 nano-particles.

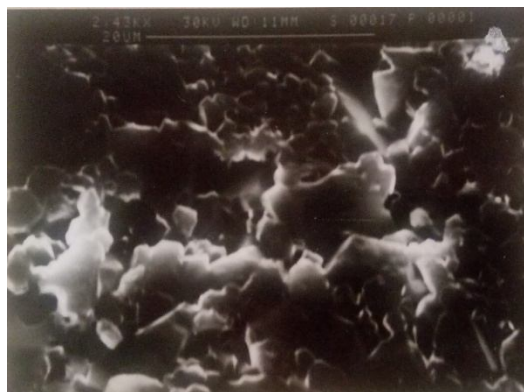


Fig. 6(a):90% $Sb_{0.6}:Sn_{0.4}$ alloy + 10% glass frits



Fig. 6(b): Pure Alumina substrate (Etched)

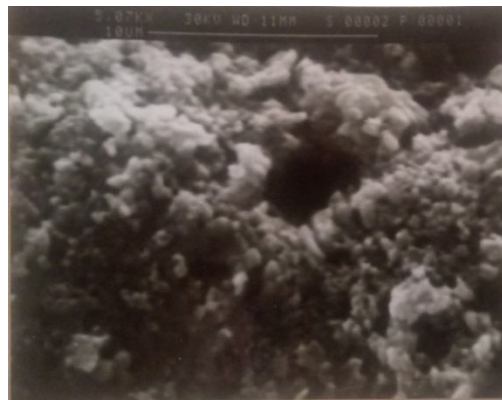
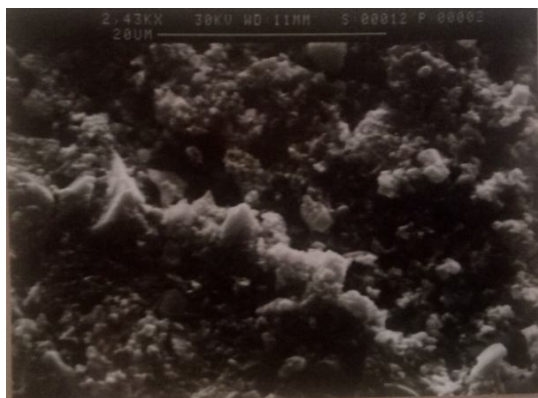


Fig. 6(c): 45%SnO₂ + 45%Sb_{0.6}:Sn_{0.4} alloy + 10% glass

Fig. 6(d): 87% SnO₂ + 3% Sb_{0.6}:Sn_{0.4} alloy + 10%

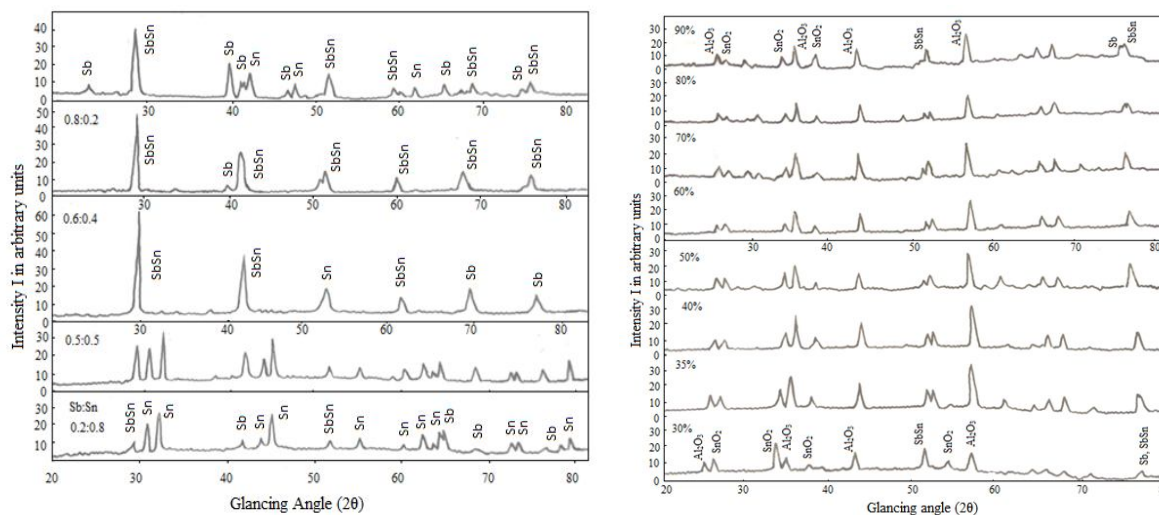


Fig. 7(a): XRD patterns of Sb:Sn alloys prepared

Fig. 7(b): XRD patterns of SnO₂ based Sb_{0.6}:Sn_{0.4} with different compositions heated at 630 °C . alloy loaded TFRs fired at 800 °C

V. CONCLUSIONS

The electrical characterization of SnO₂ nano-particle based thick film resistors loaded with an optimized Sb_{0.6}:Sn_{0.4} alloy that gives minimum sheet resistivity and TCR was used to produce in the range of sheet resistivity of thick film resistors from $3 \times 10^{12} \Omega/\square$ to 1.71 k Ω/\square and TCR in the range -3145 to -814 ppm/ °C. Further theoretical and experimental values of percolation threshold observed at 0.2-0.3 and 0.07 weight fractions, differ on account of ideal assumptions for the Springette's effective conductivity model, wherein spherical alloy particles with constant conductivity metallic particles were supposed to be embedded in SnO₂ insulating matrix. The model needs modification for non-uniformity of microstructure and carefully designed experiments.

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